Electronic Version v1.1

Stylesheet Version v1.1

SUBMISSION TYPE:			NEW ASSIGNMENT		
NATURE OF CONVEY	ANCE:		ASSIGNMENT		
CONVEYING PARTY	DATA				
		N	ame	Execution Date	
IFIRE TECHNOLOGY	Í INC.			01/05/2005	
RECEIVING PARTY D	ΑΤΑ				
Name:	IFIRE TECHI	NOLOG	Y CORP.		
Street Address:	10102 114 S	TREET			
City:	FORT SASK	ATCHE	WAN		
State/Country:	CANADA				
Postal Code:	T8L 3W4				
PROPERTY NUMBER	S Total: 1				
Property Ty	vpe		Number		L L
Application Number:		11122	301		112301
CORRESPONDENCE	DATA				
Fax Number:	(303)49	9-8089			e
			hen the fax attempt is unsuccessful.		00 00\$
Email:	winner@		vin.com er and Sullivan		v
Correspondent Name: Address Line 1:	4875 Pe				
Address Line 2:	Suite 20				
Address Line 4:	Boulder	, COLO	RADO 80301		
NAME OF SUBMITTE	R:		Michael J. Curtis		
Total Attachments: 5 source=36-00D assign source=36-00D assign source=36-00D assign source=36-00D assign source=36-00D assign	#page2.tif #page3.tif #page4.tif				

WHEREAS, IFIRE TECHNOLOGY INC., having a principal office or place of

business at 10102 - 114 Street, Fort Saskatchewan, Alberta, Canada, T8L 3W4, (hereinafter referred to as the "ASSIGNOR") is the owner of the entire right, title and interest in the patents and patent applications listed in Schedule "A", attached hereto; and

WHEREAS, the ASSIGNOR assigned the patents and patent applications listed in Schedule "A" to 1115901 ALBERTA LTD. on July 1, 2004; and

WHEREAS, 1115901 ALBERTA LTD. changed its name to IFIRE TECHNOLOGY CORP. on July 7, 2004; and

WHEREAS, IFIRE TECHNOLOGY CORP., whose full post office address is 10102 - 114 Street, Fort Saskatchewan, Alberta, Canada, T&L 3W4, (hereinafter referred to as the "ASSIGNEE"), is desirous of securing the entire right, title, and interest in and to said patent applications, the patents to be issued upon said applications and the inventions and discoveries disclosed and claimed therein;

NOW THEREFORE, for good and valuable consideration, the receipt and sufficiency of which is hereby acknowledged, ASSIGNOR has sold, assigned and conveyed, and hereby sells, assigns and conveys to ASSIGNEE, its successors and assigns, its entire right, title and interest in and to the inventions and discoveries disclosed in the patents and patent applications listed in Schedule "A", including all other patent applications and any corresponding patent rights in any and all foreign countries which have been or shall be filed on any of the inventions and discoveries disclosed and claimed in any of said patents and patent applications, and all divisions, reissues, continuations, renewals and prolongations thereof, and further including all rights of priority under the International Convention in foreign countries and the right to file and prosecute such applications, and in and to any and all patents which have been or may be granted by any country based either in whole or in part upon any or all of said inventions and discoveries of the said patents and patent applications;

ASSIGNOR has sold, assigned and conveyed, and further sells, assigns and conveys to ASSIGNEE all claims by reason of past infringement of the said patents and patent applications, including the right to sue for and collect for said past infringements;

ASSIGNOR has authorized and requested, and hereby authorizes and requests the Commissioner of Patents in Canada and any official of any foreign country whose duty it is to issue

PATENT REEL: 016235 FRAME: 0121

patents on said applications, to issue all patents for said inventions to the ASSIGNEE, its successors and assigns, in accordance with the terms of this Assignment;

ASSIGNOR has covenanted, and hereby covenants that it has the right to convey the entire right, title and interest to ASSIGNEE, herein assigned, and that it has not executed, and will not execute, any agreement in conflict therewith;

ASSIGNOR has agreed, and hereby agrees that it will, without further consideration, communicate with and provide to ASSIGNEE, its successors and assigns, all facts known and documents available to ASSIGNOR relating to said inventions, discoveries, patents and patent applications, including the histories thereof; testify in any legal proceedings; execute and secure all papers that may be necessary to file, prosecute and maintain said patents and patent applications in any country and to assign the same; make all rightful oaths; and generally do everything possible to aid ASSIGNEE, its successors, assigns and nominees, to obtain, uphold and enforce proper patent protection for said inventions and discoveries in all countries.

SIGNED at Fort Saskatchewan, Alberta, this 5th day of January, 2005.

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IFIRE VECHNOLOGY INC. By: Name: Douglas H. Murray Title Assistant Corporate Secretary

SCHEDULE A

ountry	Application Date	Application Number	Publication Number	Patent Number	Expiry Date	Status
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	INESCENT LAM	<u>INATE WITH TE</u>	HCK FILM DIS	EP 0 639 319	6-May-13	Validated
elgium	() () ()	0 1 1 0 1 1 1	2,118,111	2,118,111	6-May-13	Issued
anada	6-May-93	2,118,111 93909709.3	0 639 319 A1	0 639 319 B1	6-May-13	Issued
urope	6-May-93	F1-945257	V 039 319 A1	FI-111322	6-May-13	Issued
inland	6-May-93	r1-945257		EP 0 639 319	6-May-13	Validated
rance			EP 0 639 319	693 136 32.4-08	6-May-13	Validated
crmany	27-Feb-98	98101573.6		1002845	6-May-13	Granted
ong Kong	Z/-FCD-90	78101373.0	27172BE/97	EP 0 639 319	6-May-13	Validated
zly	24-Dec-93	05-327981	07-050197	3,578,786	24-Dec-13	Issued
apan George	6-May-93	93 2685	07-030257	182558	6-May-13	Issued
lexico	0-1414 y-23	93 2003		EP 0 639 319	6-May-13	Validated
ietherlands	6 Mary D2	1994-703981		0315863	6-May-13	Issued
outh Korea	6-May-93	177-103701	2109490	EP 0 639 319	6-May-13	Validated
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aiwan	17-May-93	82103846	320815	NI 091149	6-May-13	issued
J.S.A.	30-May-93	08/052.702 CIP		5,432,015	11-Jul-12	Issued
/	50-01 ay-75	of 07/996,547		.		
		01,0773301211		EP 0 639 319	6-May-13	Validated
V 435b1 PROCESS OF F CONNECTORS				ANEL WITH THROU	<u></u>	
V 435b1 PROCESS OF F CONNECTORS		TROLUMINESCI 2,214,066	2,214,066		<u></u>	Published/
W 435b1 PROCESS OF F CONNECTORS Canada	6-May-93	2,214,066	2,214,066	ANEL WITH THROU	JGH-HOLE	Published/ Pending
W 435b1 PROCESS OF F CONNECTORS Canada Canada				ANEL WITH THROU 0 758 836 B1	JGH-HOLE 6-May-13	Published/ Pending Issued
W 435b1 PROCESS OF F CONNECTORS Canada Canada Surope France	6-May-93	2,214,066	2,214,066 0 758 836 A1	ANEL WITH THROU 0 758 836 B1 EP 0 758 836	JGH-HOLE 6-May-13 6-May-13	Published/ Pending Issued Vabidated
W 435b1 PROCESS OF F CONNECTORS Canada Canada Surope France France Fermany	6-May-93 6-May-93	2,214,066 96203180.3	2,214,066 0 758 836 A1 EP 0 758 836	ANEL WITH THROU 0 758 836 B1	JGH-HOLE 6-May-13	Published/ Pending Issued Validated Validated
W 435b1 PROCESS OF F CONNECTORS Canada Canada Surope France Jermany	6-May-93	2,214,066 96203180.3 2004-1	2,214,066 0 758 836 A1 EP 0 758 836 99788	ANEL WITH THROU 0 758 836 B1 EP 0 758 836	JGH-HOLE 6-May-13 6-May-13	Published/ Pending Issued Vabidated
W 435b1 PROCESS OF F CONNECTORS Canada Europe France Germany Japan	6-May-93 6-May-93	2,214,066 96203180.3 2004-1	2,214,066 0 758 836 A1 EP 0 758 836	ANEL WITH THROU 0 758 836 B1 EP 0 758 836 693 32 174.1-08 T2	GH-HOLE 6-May-13 6-May-13 6-May-13	Published/ Pending Issued Validated Validated
Jnited Kingdom W 435b1 PROCESS OF F CONNECTORS Canada Europe France France Jermany Japan Netherlands United Kingdom	6-May-93 6-May-93	2,214,066 96203180.3 2004-1	2,214,066 0 758 836 A1 EP 0 758 836 99788	ANEL WITH THROU 0 758 836 B1 EP 0 758 836	JGH-HOLE 6-May-13 6-May-13	Published/ Pending Issued Validated Validated Pending
W 435b1 PROCESS OF F CONNECTORS Danada Surope France Jermany Japan Netherlands United Kingdom W 435b2 PROCESS FOR	6-May-93 6-May-93 6-Jul-04	2,214,066 96203180.3 2004-1 div of 200	2,214,066 0 758 836 A1 EP 0 758 836 199788 02-328842	ANEL WITH THROU 0 758 836 B1 EP 0 758 836 693 32 174.1-08 T2 EP 0 758 836	6-May-13 6-May-13 6-May-13 6-May-13 6-May-13 6-May-13	Published/ Pending Issued Validated Validated Pending Validated Validated
W 435b1 PROCESS OF F CONNECTORS Canada Europe France Germany Japan Netherlands United Kingdom W 435b2 PROCESS FOR ADDRESS LIN	6-May-93 6-May-93 6-Jul-04 6-Jul-04	2,214,066 96203180.3 2004-1 div of 200 NG AND AN ELE	2,214,066 0 758 836 A1 EP 0 758 836 199788 02-328842	ANEL WITH THROU 0 758 836 B1 EP 0 758 836 693 32 174.1-08 T2 EP 0 758 836 EP 0 758 836	6-May-13 6-May-13 6-May-13 6-May-13 6-May-13 6-May-13	Published/ Pending Issued Validated Validated Pending Validated Validated R SCRIBED Allowed
W 435b1 PROCESS OF F CONNECTORS Canada Europe France France Fermany Vapan Netherlands United Kingdom W 435b2 PROCESS FOR ADDRESS LINI Canada	6-Мау-93 6-Мау-93 6-ЈцІ-04 6-ЈцІ-04 LASER SCRIBJ ES 6-Мау-93	2,214,066 96203180.3 2004-1 div of 200 NG AND AN ELE 2,214,044	2,214,066 0 758 836 A1 EP 0 758 836 99788 92-328842 CTROLUMINE	ANEL WITH THROU 0 758 836 B1 EP 0 758 836 693 32 174.1-08 T2 EP 0 758 836 EP 0 758 836	6-May-13 6-May-13 6-May-13 6-May-13 6-May-13 6-May-13	Published/ Pending Issued Validated Validated Pending Validated Validated R SCRIBED Allowed
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W 435b1 PROCESS OF F CONNECTORS Danada Durope France Fermany apan Netherlands United Kingdom W 435b2 PROCESS FOR ADDRESS LINI Canada Japan W 435b3 ELECTROLUM	6-May-93 6-May-93 6-Jul-04 6-Jul-04 LASER SCRIBI ES 6-May-93 12-Nov-02	2,214,066 96203180.3 2004-1 div of 200 NG AND AN ELE 2,214,044 2002-328842 div of 05-327981 MINATE WITH T	2,214,066 0 758 836 A1 EP 0 758 836 (99788 02-328842 CTROLUMINES 2,214,044 2003-157975 HICK FILM DI	ANEL WITH THROU 0 758 836 B1 EP 0 758 836 693 32 174.1-08 T2 EP 0 758 836 EP 0 758 836	GH-HOLE 6-May-13 6-May-13 6-May-13 6-May-13 6-May-13 WITH LASE	Published/ Pending Issued Validated Pending Validated Validated Validated R SCRIBED Allowed Published/ Pending
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ountry	Date	2004-146936	2004-235167			Published/
ayan.	11-14183-04	div of				Pending
		05-327981				
		00-341201				
N 4350 METHOD OF F	ORMING A DIFI	ECTRIC LAYER	IN AN ELECTRO	LUMINESCENT	LAMINATE	
J.S.A.	28-Apr-95	08/430,729 div		5,756,147	26-May-15	Issued
		of 08/052,702		·····		
W 435d	UMINESCENT I	NSPI AV PANET.				
U.S.A.	23-May-95	08/447,404 div		5,634,835	23-May-15	Issued
U.S.A.	23-1414 A-27	of 08/052,702			-	
		0100/024/104				
W 435e A PROCESS FO	R LASER SCRIP	ING A PATTERN	IN A PLANAR L	AMINATE		
U.S.A.	23-May-95	08/449,507 div		5,702,565	30-Dec-14	Issued
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AN ELECTROI	UMINESCENT 1 23-May-95	LAMINATE AND 08/447,458 div	PROCESS FOR F	5,679,472	21-Oct-14	Issued
AN ELECTROI	23-May-95	08/447,458 div of 08/052,702		5,679,472	21-Oct-14	
AN ELECTRON U.S.A. W 507 DIELECTRIC	23-May-95	08/447,458 div of 08/052,702 OW DIELECTRI	C LOSS, LOW TEI	5,679,472	21-Oct-14	
AN ELECTROI U.S.A. W 507 DIELECTRIC (MEDIUM DIEL	23-May-95 GLASSES FOR L LECTRIC CONST	08/447,458 div of 08/052,702 OW DIELECTRIC	C LOSS, LOW TEL	5,679,472	21-Oct-14	vics with
AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533	23-May-95 GLASSES FOR L LECTRIC CONST 11-Nov-97	08/447,458 div of 08/052,702 OW DIELECTRIC CANTS 86116952	C LOSS, LOW TEI 367507	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	VICS WITH
AN ELECTROI U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM	23-May-95 GLASSES FOR L LECTRIC CONST 11-Nov-97 MINESCENT LAN	08/447,458 div of 08/052,702 OW DIELECTRIC CANTS 86116952 11NATE WITH P.	C LOSS, LOW TEL 367507	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	VICS WITH
AN ELECTROI U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM DIELECTRIC	23-May-95 GLASSES FOR L LECTRIC CONST 11-Nov-97 AINESCENT LAN WITH IMPROVE	08/447,458 div of 08/052,702 OW DIELECTRIC ANTS 86116952 AINATE WITH P. D DIELECTRIC	C LOSS, LOW TEL 367507 ATTERNED PHOS PROPERTIES	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued WICS WITH Issued CK FILM
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AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada	23-May-95 GLASSES FOR L <u>ECTRIC CONST</u> 11-Nov-97 MINESCENT LAN WITH IMPROVE 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC ANTS 86116952 AINATE WITH P. D DIELECTRIC 2,371,760	C LOSS, LOW TEI 367507 ATTERNED PHOS PROPERTIES 2,371,760	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued VICS WITH Issued CK FILM Published Pending
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AN ELECTROI U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada China	23-May-95 GLASSES FOR L LECTRIC CONST 11-Nov-97 AINESCENT LAN WITH IMPROVE 12-May-00 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC CANTS 86116952 AINATE WITH PL D DIELECTRIC 2,371,760 00810274.0	C LOSS, LOW TEI 367507 ATTERNED PHOS PROPERTIES 2,371,760 1360812A	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued MICS WITH Issued CK FILM Published Pending Published Pending
AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada	23-May-95 GLASSES FOR L <u>ECTRIC CONST</u> 11-Nov-97 MINESCENT LAN WITH IMPROVE 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC ANTS 86116952 AINATE WITH P. D DIELECTRIC 2,371,760	C LOSS, LOW TEI 367507 ATTERNED PHOS PROPERTIES 2,371,760	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued VICS WITH Issued CK FILM Published Published Published Published
AN ELECTROI U.S.A. W 507 DIELECTRIC (MEDIUM DIEL Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada China Europe	23-May-95 GLASSES FOR LL <u>ECTRIC CONST</u> 11-Nov-97 MINESCENT LAN WITH IMPROVE 12-May-00 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC CANTS 86116952 ANATE WITH PA D DIELECTRIC 2,371,760 00810274.0 00929170.9	C LOSS, LOW TEL <u>367507</u> ATTERNED PHOS PROPERTIES 2,371,760 1360812A 1 188 352	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued VICS WITH Issued CK FILM Published Pending Published Pending Published Pending
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AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEN Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada China Europe Hong Kong Japan	23-May-95 GLASSES FOR L <u>ECTRIC CONST</u> 11-Nov-97 AINESCENT LAN WITH IMPROVE 12-May-00 12-May-00 31-Oct-02 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC SANTS 86116952 AINATE WITH PA D DIELECTRIC 2,371,760 00810274.0 00929170.9 02107921.7 2000-619243	C LOSS, LOW TEI <u>367507</u> ATTERNED PHOS PROPERTIES 2,371,760 1360812A 1 188 352 1046616A	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	Issued VICS WITH Issued CK FILM Published Pending Published Pending Published Pending Published Pending Published Pending
AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEN Taiwan W 533 ELECTROLUM DIELECTRIC (Canada China Europe Hong Kong Japan South Korea	23-May-95 GLASSES FOR LL <u>ECTRIC CONST</u> 11-Nov-97 AINESCENT LAN WITH IMPROVE 12-May-00 12-May-00 31-Oct-02 12-May-00 	08/447,458 div of 08/052,702 OW DIELECTRIC ANTS 86116952 AINATE WITH P. D DIELECTRIC 2,371,760 00810274.0 00929170.9 02107921.7 2000-619243 2001-7014543	C LOSS, LOW TEI 367507 ATTERNED PHOS PROPERTIES 2,371,760 1360812A 1 188 352 1046616A 2003-500805	5,679,472 MPERATURE CC NI 106548 SPHOR STRUCT	21-Oct-14 DFIRED CERAI 10-Nov-17 URE AND THIC	VICS WITH Issued CK FILM Published Pending Published Pending Published Pending Published Pending Published Pending Published Pending
AN ELECTRON U.S.A. W 507 DIELECTRIC (MEDIUM DIEN Taiwan W 533 ELECTROLUM DIELECTRIC Y Canada China Europe Hong Kong Japan	23-May-95 GLASSES FOR L <u>ECTRIC CONST</u> 11-Nov-97 AINESCENT LAN WITH IMPROVE 12-May-00 12-May-00 31-Oct-02 12-May-00	08/447,458 div of 08/052,702 OW DIELECTRIC SANTS 86116952 AINATE WITH PA D DIELECTRIC 2,371,760 00810274.0 00929170.9 02107921.7 2000-619243	C LOSS, LOW TEI <u>367507</u> ATTERNED PHOS PROPERTIES 2,371,760 1360812A 1 188 352 1046616A	5,679,472 MPERATURE CC NI 106548	DFIRED CERAI	VICS WITH Issued CK FILM Published Pending Published Pending Published Pending Published Pending Published Pending Published Pending Issued

U.S.A.	14-Aug-03	10/640,725 div	2004/0033752	Published/
	•	of 09/540,288		Pending

Country	Application Date	Application Number	Publication Number	Patent Number	Expiry Date	Status
W 533b						
	FORMING A THIC	CK FILM DIELEC	<u>TRIC LAYER IN</u>	AN ELECTROLU	JMINESCEN	<u>LAMINATE</u>
U.S.A.	14-Aug-03	10/641,231 div	2004/0033307			Published/
		of 09/540,288				Pending
) SUBSTRATE ANI MINESCENT LAM	D DIELECTRIC L	AYER COMPON	ent for use in	AN	
A COMBINED	O SUBSTRATE ANI MINESCENT LAM 14-Aug-03	D DIELECTRIC L	AYER COMPON 2004/0032208	ent for use in	AN	Published/ Pending
A COMBINED ELECTROLUI U.S.A. W 533d	MINESCENT LAM 14-Aug-03	D DIELECTRIC L INATE 10/640,789 div of 09/540,288	2004/0032208			Pending
A COMBINED ELECTROLUI J.S.A. W 533d ELECTROLUI	MINESCENT LAM 14-Aug-03 MINESCENT LAM	D DIELECTRIC L INATE 10/640,789 div of 09/540,288 UNATE WITH PA	2004/0032208			Pending
A COMBINED ELECTROLUI U.S.A. W 533d ELECTROLUI	MINESCENT LAM 14-Aug-03	D DIELECTRIC L INATE 10/640,789 div of 09/540,288 UNATE WITH PA	2004/0032208			Pending

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